THE SPIN-ORBIT SPLITTING IN THE Si BANDSTRUCTURE MEASURED BY MEANS OF SPIN-RESOLVED PHOTOEMISSION

B. Schmiedeskamp, B. Vogt and U. Heinzmann
Fakultät für Physik, Universität Bielefeld, D-4800 Bielefeld, Germany
and
Fritz-Haber-Institut der Max-Planck-Gesellschaft, D-1000 Berlin, Germany
(Received 30 April 1990 by G. Güntherodt)

Spin-, angle- and energy-resolved photoemission with circularly polarized synchrotron radiation from BESSY has been applied to deduce information about the electronic structure of silicon in the \( \Lambda \)-direction. We used the highly symmetrical experimental set-up of normal radiation incidence and normal electron emission. This method, which has in the past several times been applied to metals and rare gas crystals with medium and high atomic numbers, has thus been applied now to a semiconductor with a low atomic number \((Z = 14)\). For photon energies between 5.5 and 10 eV we find a peak \( V \) in the photoemission spectra which corresponds to a transition from the valence bands in the bulk band structure of silicon in the \( \Lambda \)-direction. The electrons which contribute to the peak are spin polarized due to a spin-orbit splitting \( \Delta E_{\text{so}} \) smaller than 50 meV. Adsorption of \( 0.5 \text{ML} \) Ag or Au induces band bendings and work function changes and yields a sharper peak and less secondary electron background than the clean Si(1 1 1)-surface. For both the clean and adsorbate covered surface and \( k_{\perp} \) away from \( \Gamma \) we determine \( \Delta E_{\text{so}} \) from a spin analysis of peak \( V \) and find values between 20 and 35 meV with typical errors of 10 meV. These values in \( \Lambda \)-direction are smaller than the \( \Delta E_{\text{so}} \)-value of 44 meV at the \( \Gamma \)-point [1, 2].

1. INTRODUCTION

ANGLE- AND energy-resolved photoemission is an often used method for bulk bandstructure determination [3-7] and references therein. In the past the method has mainly been applied to metals while fewer studies were performed on semiconductors [3-7]. Examinations of the bulk bandstructure of Si in the \( \Lambda \)-direction were performed by Uhrberg et al. [8]. For photon energies between 10 and 17 eV they demonstrate that transitions exist from the valence bands into a free electron like final band.

Spin-resolved photoemission with circularly polarized radiation from nonmagnetic crystals yields further information about the electronic bandstructure, especially with respect to the symmetry of bands involved in transitions, spin-orbit splittings and hybridization [5-7, 9-14]. With spin-resolved and energy-integrated photoemission Bona et al. [1] show that a spin-orbit splitting smaller than 50 meV exists at the \( \Gamma \)-point of the silicon bulk bandstructure.

In this work we study the bulk bandstructure of silicon in the \( \Lambda \)-direction with spin-, energy- and angle-resolved photoemission. For photon energies between 6 and 10 eV we study transitions from the valence bands into the first final band above the vacuum level and determine the valence band spin-orbit splittings for several \( K_{\perp} \)-values away from \( \Gamma \). The same procedure is applied to Si(1 1 1) surfaces which were covered with 0.5 monolayers Ag or Au.

2. EXPERIMENTAL

The experiments were performed with circularly polarized radiation from the storage ring BESSY in an apparatus which is described in [7]. We used the highly symmetrical experimental set-up of normal radiation incidence and normal electron emission. Angle- and energy-analysis of the photoelectrons was accomplished with an electron spectrometer which is described in [15]. The overall energetic resolution (electrons plus photons) was better than 150 meV, the angular resolution \( \pm 3^\circ \). The Si(1 1 1)-sample was an \( n \)-type \((10-20 \Omega \text{cm})\) single crystal which was aligned within
0.5 degrees with the [1 1 1]-direction and within 0.3° with the light direction. The samples were heated to 900°C at background pressures in the $10^{-10}$ mbar range in order to remove an oxide protection layer and to prepare an ordered ($7 \times 7$) silicon surface. The base pressure in the system was lower than $3 \times 10^{-10}$ mbar. The crystal surface has been controlled by Auger electron spectroscopy (AES) and LEED. The metal coverages were obtained by evaporating 0.5 monolayers of Ag or Au, while the sample was kept at room temperature. We used resistively heated evaporators which are surrounded by a cooled shield [16]. The metal beams pass, in addition, a 1 cm diameter tube before they reach the silicon surface which is positioned at a distance of 20 cm from the source. After evaporation the metal covered Si-crystal was heated to 500°C and revealed then a clear $1/3 \times 1/3 \sqrt{3} R 30°$-structure for Ag (denoted as Si(1 1 1)$\sqrt{3}$ Ag) and a $5 \times 1$ structure for Au (denoted as Si(1 1 1)(5 × 1)Au).

3. RESULTS AND DISCUSSION

Photoemission spectra obtained for the clean silicon surface are given in Fig. 1. The left column shows non-spin-resolved data for photon energies between 5 and 10 eV. One peak (V) is resolved in the spectra. It emerges out of the secondary electron background at $h\nu \approx 7$ eV, is best resolved at 8 eV and decreases then rapidly for higher photon energies. The binding energy of peak V increases continuously with photon energy. The corresponding spin-resolved photoemission spectra are given in the right part of Fig. 1. Circles are the non-spin-resolved photoemission intensities $I$. By means of the measured spin-polarization $P$ they are separated into the partial intensities $I_+ = I/2(1 + P)$ and $I_- = I/2(1 - P)$. $I_+$ and $I_-$ (the dashed and solid lines in the right column of Fig. 1) denote then the electron intensities with spin parallel and antiparallel to the photon spin, respectively. It is obvious from the data that the electrons which contribute to peak V in the spectra in the right column of Fig. 1 are slightly spin-polarized with the $I_-$ part dominating at lower binding energies. For an interpretation of the data we regard the bulk bandstructure of silicon in the A-direction which is given in Fig. 2. The bandstructure, which is a calculation of Persson, is taken from [8].

The slight dispersion of peak V in Fig. 1 and its drastic intensity decrease at $h\nu \approx 9$ eV fit excellently into the picture that peak V is due to transitions from the A$_3$-valence band in Fig. 2 into the first calculated A$_5$-final band above the vacuum level. This is indicated by the arrows in Fig. 2. The bandstructure in Fig. 2 is a non-relativistic calculation. From relativistic calculations for several diamond lattice crystals [17] it is known that the A$_3$-valence band of the non-relativistic bandstructure splits into a A$_{3.5}$-band and a A$_5$-band due to spin-orbit interaction with the A$_{1.5}$-band at lower binding energy. For a transition from a A$_{3.5}$-band into a A$_5$-band we expect negatively spin-polarized photoelectrons [18]. This is indeed what we see in the right column of Fig. 1; it supports thus the opinion that this spin-polarization is due to the spin-orbit splitting of the A$_5$-valence band.

A similar set of data was measured for Si(1 1 1) surfaces covered with 0.5 monolayer Ag and Au-adsorbates as described above. Results for the Si(1 1 1)–$\sqrt{3} \times 3$Ag surface are given in Fig. 3. The left and right
columns show again the non-spin-resolved and spin-resolved spectra. Compared to the spectra in Fig. 1 we find a slightly reduced work function, a bending of the valence bands by about 0.2 eV towards lower binding energy, a lower secondary electron background and a sharper peak \( V \) which is probably due to a more perfect ordering of the Si surface in the \( \sqrt{3} \) structure. These findings allow a study of the spin-polarization behaviour of peak \( V \) also for lower photon energies, as can be seen in the right column of Fig. 3. We get more than 10 percent spin-polarization for electrons with energies just above the vacuum level while the spin-resolved photoemission spectrum for \( \nu = 7.5 \) eV differs slightly (at the high binding energy side of the \( I_+ \) and \( I_- \)-peaks) from the 8 eV spectrum in Fig. 1. Spectra for the Au covered surface (not displayed) agree with respect to the shape of peak \( V \) and the secondary electron background with the Ag covered surface and yield also spin-polarized electrons. An apparently consistent result is that the integrated \( I_+ \) intensity is in all the measured spectra less than that of \( I_- \). This is possibly due to hybridization of the \( \Lambda_1 \)- and \( \Lambda_3 \)-valence band in Fig. 2. As already described above a relativistic bandstructure calculation yields an additional splitting of the \( \Lambda_1 \)-band into a \( \Lambda_3 \)- and a \( \Lambda_2 \)-band, while the \( \Lambda_3 \)-band becomes a \( \Lambda_2 \)-band. One expects then also hybridization and an avoided crossing point of the \( \Lambda_3 \) and the \( \Lambda_1 \)-band near \( \Gamma \) [17]. Earlier spin resolved studies of Pd(1 1 1) [11] yielded indeed lower photoelectron intensities for transitions from a \( \Lambda_3 \)-band in the neighbourhood of an avoided crossing point [19] with a \( \Lambda_1 \)-band. This explains especially the high spin polarization values in the 5 eV spectrum in the lower right part of Fig. 3.

We use both the spin-resolved and the non-spin-resolved data of the clean and metal covered Si(1 1 1) surfaces to perform a spin-resolved bandmapping of the \( \Lambda_3 \) valence bands. The upper part of Fig. 4 displays the binding energies of peak \( V \) as determined from the non-spin-resolved spectra in Figs. 1 and 3. A comparison of this binding energies with the bandstructure in Fig. 2 shows that very good agreement is obtained with the calculated \( \Lambda_3 \)-band. In the lower part of Fig. 4 we present the values for the spin-orbit splitting \( \Delta E_{so} \) which have been determined from the spin-resolved photoemission spectra. Squares are the data for the clean Si-surface, circles and triangles represent the \( \Delta E_{so} \)-values for the Ag- and Au-covered surfaces, respectively. We obtain values between about 20 and 35 meV with typical errors of 10 meV not depending on whether the Si surface is metal covered or not. It is worth noting, that the experimentally obtained spin-orbit splitting of about 30 meV is a factor of 4 smaller than the resolution of our electron spectrometer used.
THE SPIN-ORBIT SPLITTING IN THE Si BANDSTRUCTURE

Acknowledgements — We acknowledge discussions with N. Irmer, N. Müller and P. Stoppiamans as well as the support of the BESSY staff. The work was financially supported by the BMFT (05431).

REFERENCES

18. M. Wöhlcke & G. Borstel, in Optical Orientation, (Edited by F. Meier & B.P. Zakharchenya), Elsevier Science Publ. 1984; one should note that we denote the spin-polarization as positive, if electron and photon spin are parallel; this is just opposite to the definition given by Wöhlcke and Borstel.
19. See the spin-resolved photoemission spectra for 9 eV photon energy in Fig. 3 of [11].

It demonstrates again [11], that the spin-polarization analysis of photoelectron peaks increases the overall energetic sensitivity compared to non-spin-resolved photoelectron spectroscopy. Finally, we compare our results with the \( \Delta E_{\text{SO}} \)-value, which is known to be 44 meV at the \( \Gamma \)-point [1, 2] and note that our values which were all obtained for \( K_{\text{f}} \)-values away from \( \Gamma \) are systematically lower.

4. CONCLUSIONS

We have studied the electronic structure of Si in the \( \Lambda \)-direction with spin-, angle- and energy-resolved photoemission. One peak \( V \) is resolved in the photoemission spectra. \( V \) corresponds to transition from a \( \Lambda_{3} \)-valence band into the first unoccupied band above the vacuum level. The electrons which contribute to \( V \) are spin-polarized due to the spin-orbit splitting of the \( \Lambda_{3} \)-band. Analysis of the data leads to values of the spin-orbit splittings of this band between 20 and 35 \( \pm \) 10 meV. The same studies were done for well ordered Si(111)-\( \sqrt{3} \) Ag and Si(111)(5 \( \times \) 1) Au surfaces. While work functions and band bending are altered by the metal adsorption the spin-orbit splitting of peak \( V \) seems to be unaffected by the metal adsorption.